

Feature

Pass Bands: $16\text{GHz} \sim 17\text{GHz}$, $18\text{GHz} \sim 19\text{GHz}$, $20\text{GHz} \sim 21\text{GHz}$;

Insertion Loss in pass bands: ≤11dB Isolation between pass bands: ≥30dB

Size: 4.6x4.1x0.15mm

Description

This device is a FET switch filter bank MMIC based on GaAs processing. Adopt +5V/0V logic control, switching time is less than 30ns typ. It has low loss, excellent isolation, and high integration.

The metallization processing of thru-holes on the plate ensures good grounding. Extra grounding measures aren't required, which is easy for application. The back metallization is suitable for eutectic sintering or conductive adhesive sticking processes.

Absolute Rating

Control Voltage	-1.5V~+6V
Input Power	30dBm
Storage Temperature	-65~+150°C
Operating Temperature	-55~+125°C

Electrical Specifications 1 (T_A=+25°C)

Spec.	Pass band 1	Pass band 2	Unit
Freq. Range	16~17	18~19	GHz
Insertion Loss	≤11	≤11	dB
Rejection	≥30@7GHz-14GHz ≥30@7GHz-14GHz		dBc
	≥25@18GHz-30GHz	≥25@18GHz-30GHz	dBc
VSWR	≤1.8		_

Electrical Specifications 2 (T_A=+25°C)

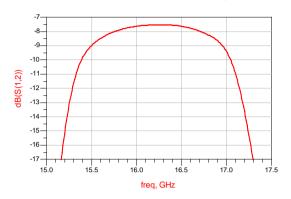
Spec.	Pass band 3	Unit
Freq. Range	20~21	GHz
Insertion Loss	≤11	dB
Rejection	≥30@7GHz-18GHz	dBc
	≥25@22GHz-30GHz	dBc
VSWR	≤1.8	_

S2P file name: BWSBF-16_21-3.s2p

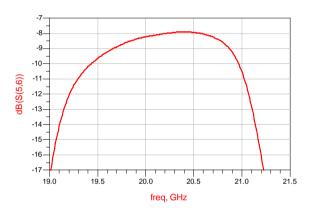


Typical Test Curves

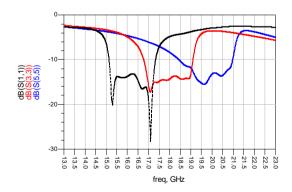
Pass band 1 Insertion Loss VS Frequency (T_A=25°C)



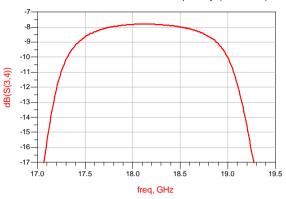
Pass band 3 Insertion Loss VS Frequency (T_A=25°C)



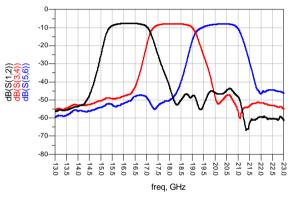
Return Loss VS Frequency (T_A=25°C)



Pass band 2 Insertion Loss VS Frequency (T_A=25°C)

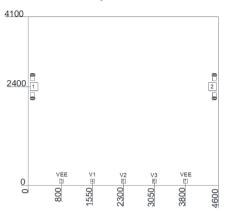


Insertion Loss VS Frequency (T_A=25°C)





Mechanical Specification



Truth Table

Control Voltage(VEE=-5V)		Pass bands	
V1	V2	V3	Pass Dalius
0V	5V	5V	16~17GHz
5V	0V	5V	18~19GHz
5V	5V	0V	20~21GHz

PINS Definitions

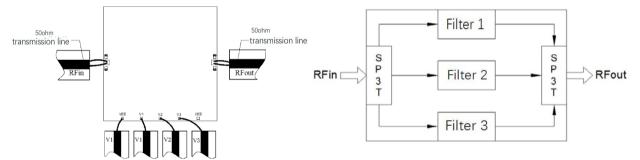
Symbol	Description
RF1, RF2	RF Input, RF Output
V1, V2, V3	Control ports
VEE	Power Supply ports

Notes:

- 1. Dimensions are um. Tolerance: ±0.05mm
- 2. Die thickness is 0.1mm
- 3. Typical bond pad is 100 μ *100 μ , which is 50 μ away from chip edge.
- 4. The bottom of the device is gold plated, should be grounded.

Recommended Assembly Diagrams

Functional Diagram



Application Notes:

- 1. The chip is back-metallized and can be die-mounted with AuSn eutectic preforms or with electrically conductive epoxy.
- 2. The die should be assembled on carriers like Kovar or Mu-Cu which have same Coefficient of thermal expansion. $(5.8 \times 10-6/)$ with GaAs.
- 3. Recommend using Φ 25um Au wire for bonding, whose length is around 200um.
- 4. Sinter by AuSn (80/20), which doesn't exceed 300°C within 30 seconds max.
- 4. Handle the chips in a clean environment. DO NOT attempt to clean the chip using liquid cleaning systems.
- 5. Handle the chip along the edges with a vacuum collet or with a sharp pair of bent tweezers.
- 6. The device is sensitive to ESD. ESD protection is required during storage and usage.
- 7. If you have any questions, please contact us.